

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Inventor(s) : Franz LAERMER et al.
Serial No. : 10/524,610
Filed : August 11, 2005
For : LAYER SYSTEM HAVING A SILICON LAYER AND A
PASSIVATION LAYER, METHOD FOR CREATING A
PASSIVATION LAYER ON A SILICON LAYER AND ITS
USE
Examiner : Hoang Ho
Art Unit : 2818
Confirmation No. : 9981

Mail Stop Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, Virginia 22313-1450

I hereby certify that this correspondence is being electronically transmitted to the United States Patent and Trademark Office via the Office electronic filing system on **May 22, 2009**.

Signature: /Wendy Espinal/
Wendy Espinal

AMENDMENT

S I R:

In response to the Office Action of January 22, 2009 (*the three-month response date which is extended by one month by the accompanying Transmittal and Request for Extension of Time, from April 22, 2009 to May 22, 2009*), kindly amend the above-captioned application without prejudice as follows:

Amendments to the Specification begin on page 2 of this paper.

Amendments to the Claims are reflected in the listing of claims, which begins on page 3 of this paper.

Remarks begin on page 6 of this paper.